

## United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS WASHINGTON, D.C. 20201 WWW.umpto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	ATTORNEY DOCKET NO. CONFIRMATION NO	
09/939,647	08/28/2001	Shigeru Umehara	N99147USDIV	N99147USDIV 5529	
21254	7590 03/27/2003				
MCGINN & GIBB, PLLC 8321 OLD COURTHOUSE ROAD SUITE 200			EXAMINER		
			MACKEY, TERRENCE M		
VIENNA, VA	A 22182-3817		ART UNIT PAPER NUMBE		
			1765	5	
			DATE MAILED: 03/27/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	-gi
'		09/939,647 UMEHARA, SHIC		RÚ
Office Action Summary		Examiner	Art Unit	
		Terrence Mackey	1765	
Period fo	The MAILING DATE of this communication app or Reply		the correspondence add	Iress
- Exter after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1: SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply operiod for reply is specified above, the maximum statutory period v re to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ad patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a rep y within the statutory minimum of thirty ( vill apply and will expire SIX (6) MONTh	ly be timely filed  (30) days will be considered timely.  45 from the mailing date of this cor	nmunication.
1)	Responsive to communication(s) filed on			
2a)□		— · is action is non-final.		
3) 🗆	Since this application is in condition for allowa		are procedution as to the	morito io
Dispositi	closed in accordance with the practice under a on of Claims	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.	ments is
4)⊠	Claim(s) $1-4$ is/are pending in the application			
•	4a) Of the above claim(s) is/are withdraw	vn from consideration.		
	Claim(s) is/are allowed.			
6)⊠	Claim(s) 1 - 4 is/are rejected.			
7)	Claim(s) is/are objected to.			
8)[	Claim(s) are subject to restriction and/or	election requirement.		
Application	on Papers	·		
9)□ T	The specification is objected to by the Examiner	•		
10)∐ T	The drawing(s) filed on is/are: a)□ accept	ted or b) objected to by the	Examiner.	
	Applicant may not request that any objection to the	drawing(s) be held in abeyand	ce. See 37 CFR 1.85(a).	
11)∐ T	he proposed drawing correction filed on		approved by the Examiner.	
	If approved, corrected drawings are required in repl			
	he oath or declaration is objected to by the Exa	miner.		
Priority u	nder 35 U.S.C. §§ 119 and 120			
13)🛛 🗸	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 1	19(a)-(d) or (f).	
	]All b)□ Some * c)□ None of:		•	
•	1. Certified copies of the priority documents	have been received.		
2	2. Certified copies of the priority documents		lication No. 09/535741 .	
3	3. Copies of the certified copies of the priorit application from the International Bure	ly documents have been rec	ceived in this National St	age
	ee the attached detailed Office action for a list o			
	knowledgment is made of a claim for domestic			pplication).
a) 15)∐ Ad	$\square$ The translation of the foreign language prov cknowledgment is made of a claim for domestic	ISIONAL application has been	received.	
Attachment(s	s)	Priority under 55 0.5.0, 88	IZV dIIU/VI IZI.	
1) Notice 2) Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Infor	nmary (PTO-413) Paper No(s). mal Patent Application (PTO-1	· 52)
6. Patent and Trad TO-326 (Rev.	04.04)	on Summary	Dart of De	aper No. 5

Art Unit: 1765

#### **DETAILED ACTION**

### Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 3 – 4 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. Page 30, line10, through page 31, line 29 of the applicant's specification describe the process steps for making a through hole in ink supply plate (30) by process steps of forming a first resist film and second resist film on a first and second surface in the ink supply plate (30) and in particular disclose that the resist films should be offset from each other so that the applicant's "half etching" process will result in a displacement amount "A" of the center "C1" of the upper passage portion relative to the center "C2" of the lower passage portion. The examiner notes that claims 3 - 4 are directed to forming offset resist masks on a first and second surface of the first plate which is disclosed as being used for the formation of the pressure generating chamber of the ink jet recording head.

# Claim Rejections - 35 USC § 102/103a

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

Art Unit: 1765

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1 - 2 are rejected under 35 U.S.C. 102(b) as being anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over, Yotsuya et al., JP 06055733A. Applicant discloses a method for forming a through hole in a first plate which is to be sandwiched between a second and third plate to form an ink jet recording provided with a pressure generating chamber constructed of the first plate, and wherein the through hole is made by forming a first resist film and a second resist film on a first and second surface of said first plate, wherein the first resist film and second resist film assume substantially the same shape but are different in length from each other when measured in a direction parallel to a flow direction of ink, and forming said through hole in said first plate by etching both said first and second surface of said first plate with use of said first resist film and second resist film both of which serve as etch masks.

Yotsuya et al. teach a method for manufacturing an ink jet recording head provided with a pressure generating chamber, wherein the pressure generating chamber is constructed of a first plate sandwiched between a second and third plate

Art Unit: 1765

and wherein the first plate is provided with a through hole and one of the second plate or third plate is provided with an ink outlet passage in its ink discharge side. Yotsuya et al. discloses a method for making a through hole in a silicon substrate to serve as the first plate member by coating resist films on both faces of the silicon substrate and patterning the resist films to form mask openings which are different in length from each other as measured in a direction parallel to a flow direction of ink and etching the silicon substrate to form the through hole therein.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to perform Yotsuya's method on a first plate of approximately 140 micron thickness with a difference in length between said first resist film and said second resist film of from 80 to 140 micron as these dimensions are inherent in the Yotsuya reference.

#### Conclusion

Remaining references cited of interest to show the state of the art.

No claim is allowed.

Papers relating to this application may be submitted to Technology Sector 1700 by facsimile transmission. Papers should be faxed to Crystal Plaza 3, Art Unit 1765, using fax number (703) 305-6357. All Technology Sector 1700 fax machines are available to receive transmissions 24 hrs/day, 7 days/wk. Please note that the faxing of such papers must conform to the Notice published in the Official Gazette, 1096 OG 30, (November 15, 1989).

Art Unit: 1765

Any inquiry concerning this communication or earlier communications from the Examiner should be directed to Terrence Mackey whose telephone number is (703) 305-5504. The Examiner can normally be reached Monday - Friday from 7:00 AM – 4:30 PM.

If attempts to reach the Examiner by telephone are unsuccessful, the examiner's supervisor, Ben Uteck, can be reached at (703) 308-3836.

Any inquiry of a general nature or relating to the status of this application should be directed to the receptionist whose telephone number is (703) 308-0661.

**TMM** 

March 21, 2003

ROBERT KUNEMUND PRIMARY EXAMINER